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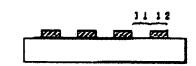
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54) BOARD FOR GALLIUM NITRIDE CRYSTAL GROWTH, AND ITS APPLICATION 57)Abstract:

'ROBLEM TO BE SOLVED: To provide a substrate for GaN rystal growth with which a high quality GaN substrate which s thick and moreover does not contain defects such as a ransposition, etc., can be obtained, and the manufacture of a iaN semiconductor element using it.

SOLUTION: A mask region 12 covered with a mask layer 2 nd nonmask region 11, where the base substrate face is xposed, are made at the face of a base substrate 1. A naterial where crystals will not grow substantially from its wn surface is used for the mask layer. In the case of making he upper part of the mask region into low transposition, the nask region is made in such form that at least the outline ncludes two straight parallel lines y1 and y2 which extend in he direction <1-100>. Furthermore, a width w1 of two parallel traight lines is made smaller than the width of a GaN emiconductor element, and moreover is made larger than the

<11 2 0> (1 Ta a)



ridth of the active part of the element. In this case for, dividing the GaN semiconductor lement into separate pieces, it is preferable to make use of a nonmask region.

EGAL STATUS

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